

Special Issue

Challenges in Machine Learning, Artificial Intelligence, Wireless Sensor Networks and Smart Cities

Message from the Guest Editors

This Special Issue encourages original and high-quality submissions, with both applied and theoretical research approaches, related (but not limited) to the following topics:

- Machine learning;
- Deep learning;
- Artificial intelligence;
- Smart cities;
- Internet of Things;
- Wireless sensor networks;
- Visual analytics;
- Ambient intelligence;
- Robotics;
- Natural language processing.

Guest Editors

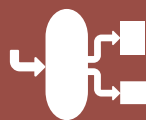
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Deadline for manuscript submissions

closed (30 November 2022)



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